

(19)  
(12)(KR)  
(A)(51) Int. Cl.<sup>7</sup>  
H05B 33/10(11)  
(43)10-2004-0058447  
2004 07 05(21) 10-2002-0084578  
(22) 2002 12 26(71) .  
20

(72) 305 701

6 가-301

(74)

(54)

, , ,  
 , , , 가 , ,  
 , , , / , , 가 , ,  
 가 , ,  
 가 , .

8e

1

2

3 2 ii - ii

4a 4i 2 ii - ii

5

6	1	.	.
7	2	.	.
- IIa - IIb	8e, 9a 9e, 10a 10e, 11a 11e , IIa-IIa	7	IIa-IIa, IIb-IIb, IIc-IIc, IId , IIb-IIb

210 : 222 :

226 : 234 :

238 : 242 : 1

250 : 258a :

258b : 258 :

271 : 278 :

286 : 294 :

326 : 1                  342 :

IV : ch :

T<sub>D</sub>:

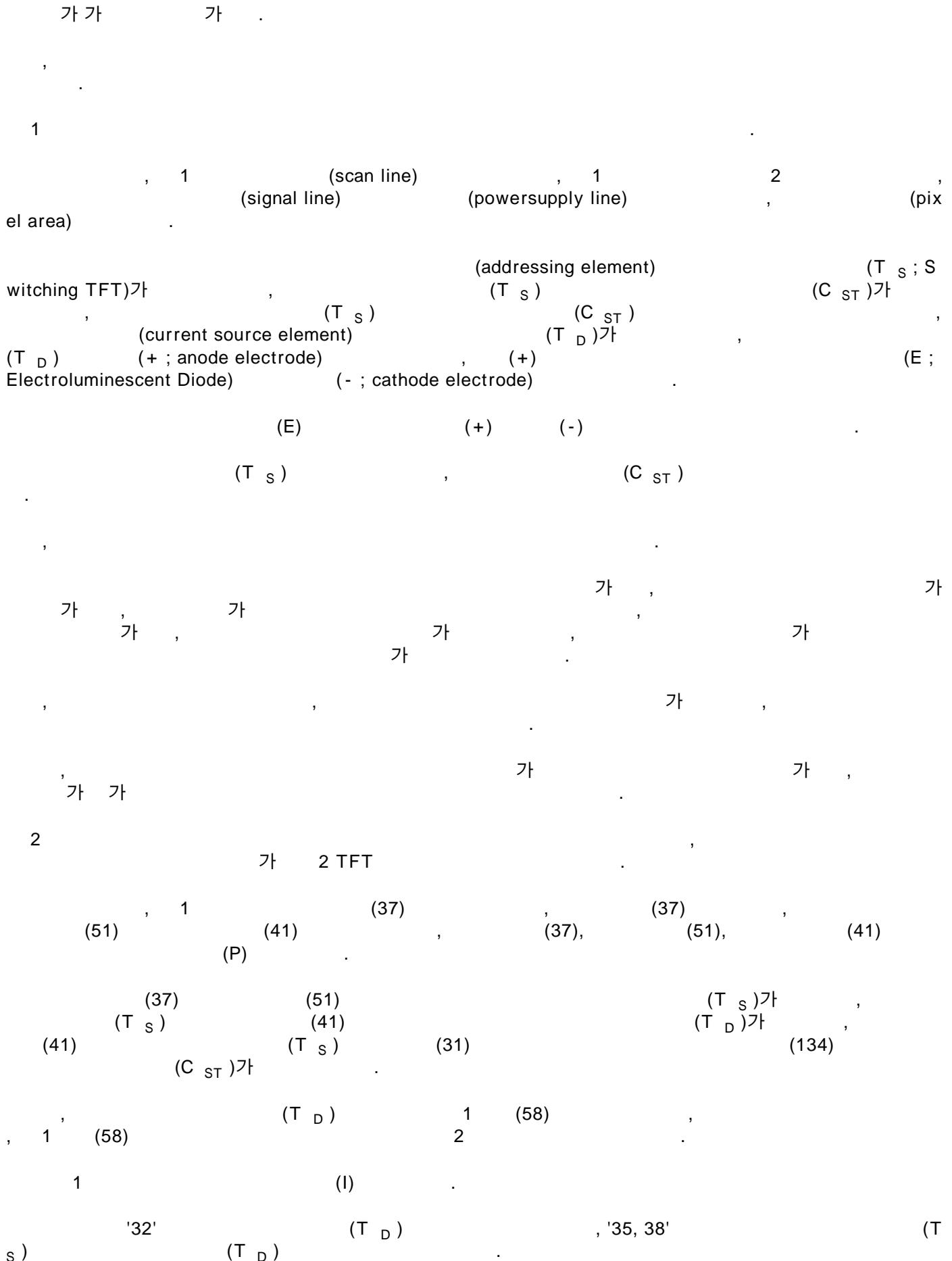
(Organic Electroluminescent Device)  
(Active-Matrix Organic Electroluminescent Device)

가 가 가 ,

(encapsulation) 가 PDP(Plasma Display Panel)

(frame) 가 가 가 가 (C<sub>ST</sub>; storage capacitance),

가



3            2            ii - ii  
 ,            (1)            (32),            (38),            (50, 52)  
 (T<sub>D</sub>) 가 ,            ,            (50)            (52)            (42)  
 ,            (42)            ,            (42)            (32)            (3)  
 4)            ,            (42)            (34)            (C<sub>ST</sub>)  
 ,            1            (58)            (64)            (66)  
 ,            (I)  
 (30)            ,            (C<sub>ST</sub>)            ,            (1)            (32)  
 (52)            (42)            2            (44)            1            (58)            1            (40)  
 ,            (T)            1            (58)            4            (60)            (50)            3            (54)  
 4            (40, 44, 54, 60)            ( )  
 ,            4a            4i            2            ii - ii            (exposure),            (development)  
 otolithography            ,            ,  
 (ph)

4a            ,            (1)            1            (30)            ,            (30)  
 ,            ,            1            (32a ; active layer)            (34)  
 ,            4b            ,            4a            ,            2            1            (38)            ,            2  
 (32a)            ,            (36)            ,            1            (40)  
 4c            ,            4b            ,            3            1            (34)            ,            1  
 (40)            (42)            2            ,            3            ,            1            (46a, 46b)            ,            4  
 ,            4d            ,            4c            (42)            ,            3            1, 2            (46a, 46b)            ,            (48)  
 )            가            2            (44)            ,  
 (32a)            ,            (iiia)  
 (iiib)            ,  
 (32a)            ,            (32b ; ohmic contact layer)            ,            (32a)            (32b)  
 (32)            ,  
 ,            4e            ,            3            ,            5            (iiib)            (32b)            (4d            48)            1  
 (4d            46a)            (50)            ,            2            (4d            46b)            (32b)            (iiia)  
 (32b)            ,            (52)            ,  
 (32),            (38),            (50, 52)  
 T<sub>D</sub>)  
 ,            (42)            ,            1            (34)            (52)  
 ,            ,            (40)            ,            (C<sub>ST</sub>)  
 4f            ,            4e            ,            4            ,            6  
 (56)            가            3            (54)            ,  
 .



2

5

가

$$\left( \begin{array}{ccccc} & & 1 & & \\ & ) & , & 1, 2 & \\ ( & & & & \\ ; & 1 & 2 & & \end{array} \right) \quad 2$$

(a-Si)

가

가

가

가

가

1. 2

가

2

## PR(photo - resist)







(286)	(271)	(232)
, (IV)	(294) (306)	,
, (V)	2	,
,	,	(234)
, (258a)	(286)	(294), (258a)
(222),	(258),	(286)
(ch)	(232)	(294)
, (T <sub>D</sub> )	2	(T <sub>D</sub> ) (286) 8c 246
2 (W)	,	,
8e, 9e, 10e, 11e (322) 310), 8) 가	, 3 (318), (342)	(T <sub>D</sub> ), 5 (322)
3	,	1 (326)
,	1 (306)	, 2 4 (330, 334, 338)
,	,	2
,	,	,
,	,	,
,	,	,
가	가	가 / 가

(57)

1

$$, \quad \begin{matrix} 1 & ( & & ) \\ 1, 2 & & & \end{matrix} \quad \begin{matrix} 2 & ( & & ) \\ & & & \end{matrix} \quad , \quad \begin{matrix} & & & ) \\ & & & , \\ 1 & ; & & ; \\ 2 & ; & & ; \end{matrix}$$

가 ,  
가 ,

2

4. 3 , , ,  
1, 2 가 , ,

5 ,

5

**8.**

3 ,

가 , , , 1 4 가

**9.**

1 3 ,

, , , , , , , , , , ;

**10.**

1 , PR(photo-resist) 1 , , , , , , , , ;

, , , , 2 1 , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

가 , 1, 2 ;

, , 1, 2 2 3 , , , , , , , , , , , , , , ;

; , , , , , , , , , , , , , , , , ;

, 3 4 , , , , , , , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

, , , , , , , , , , , , , , , , ;

**11.**

10 ,

1 , , , , , , , , , , , , , , , , ;

**12.**

10 ,

13.

10

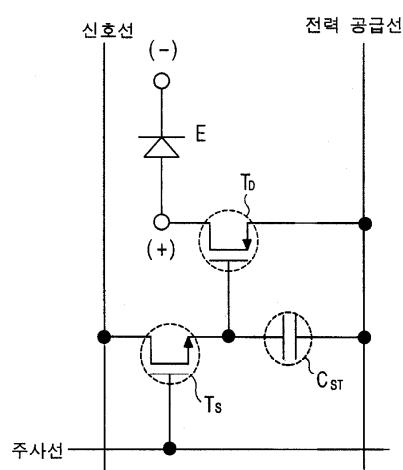
14.

10

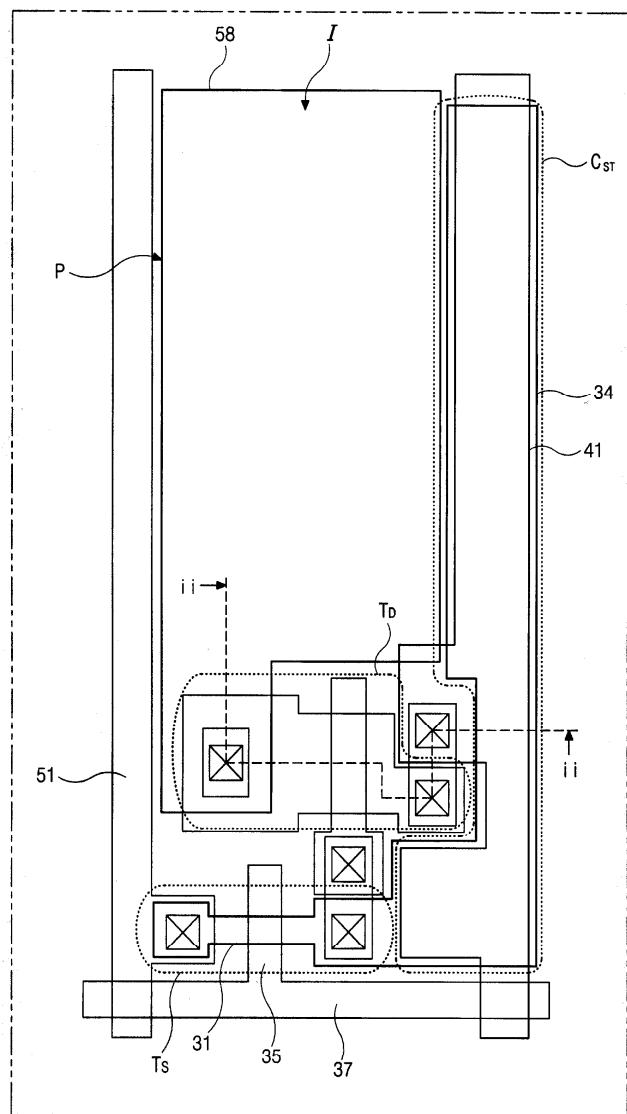
2

1

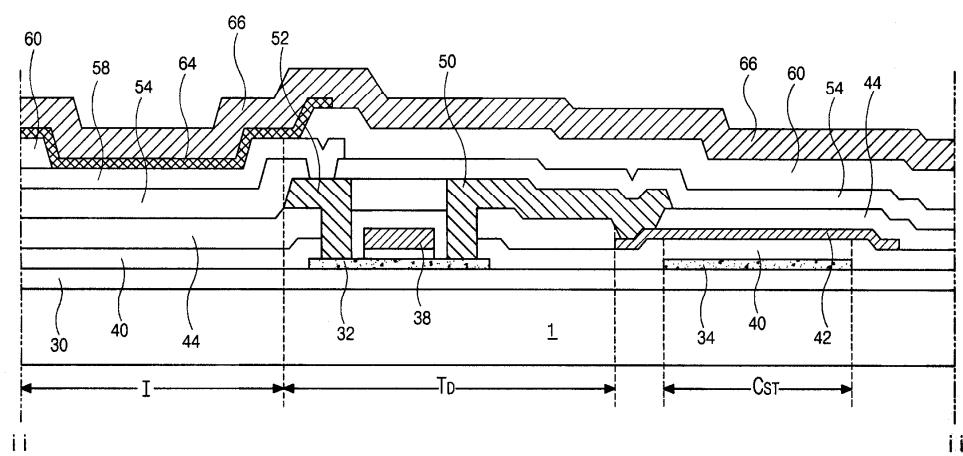
1



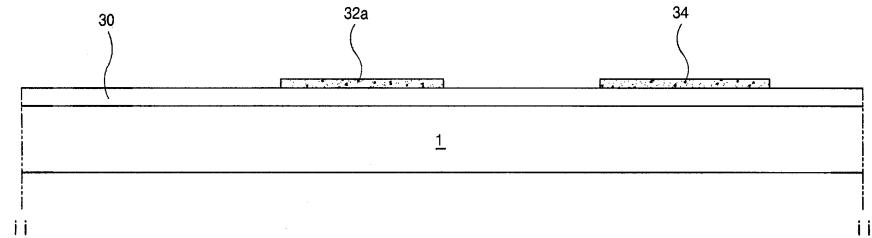
2



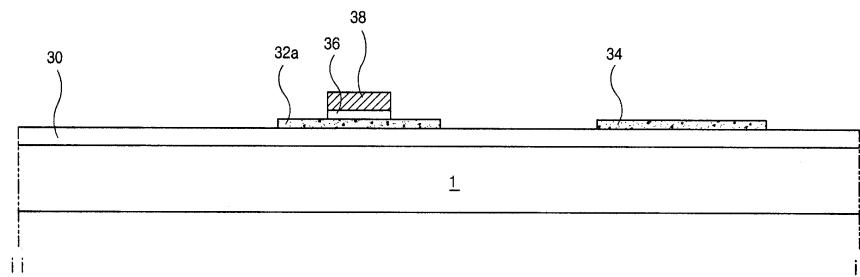
3



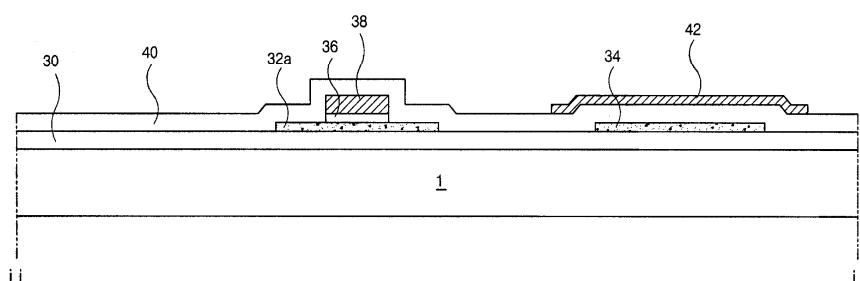
4a



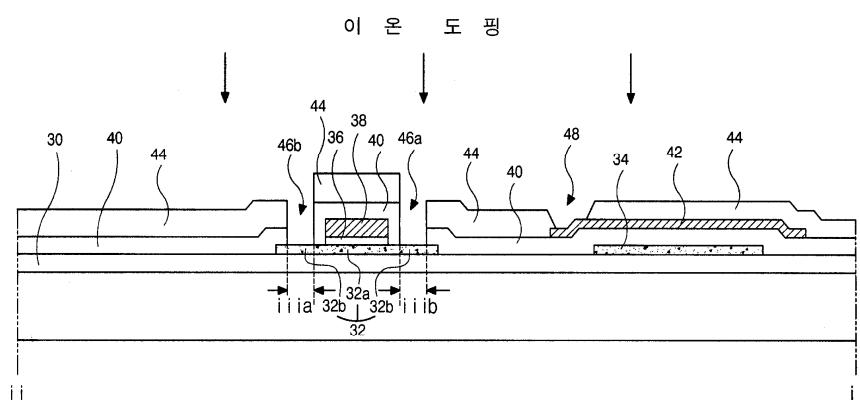
4b



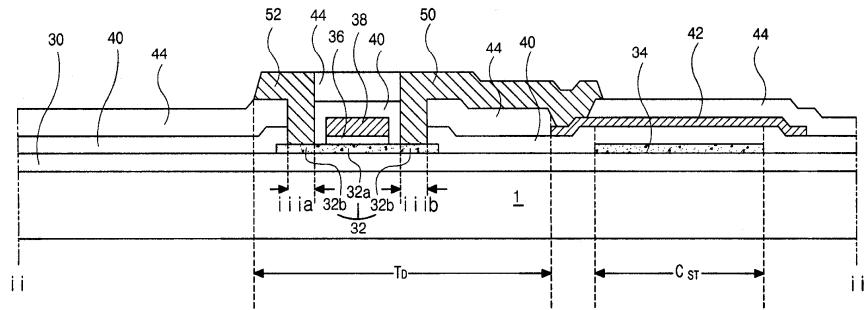
4c



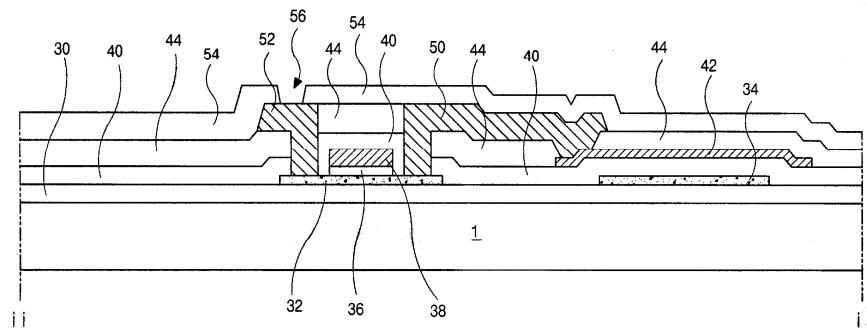
4d



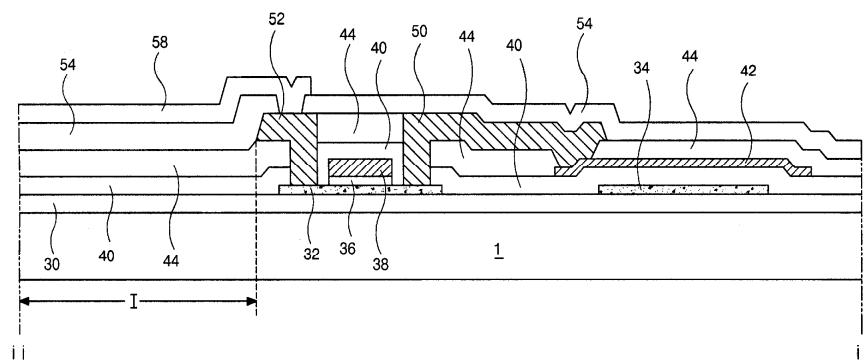
4e



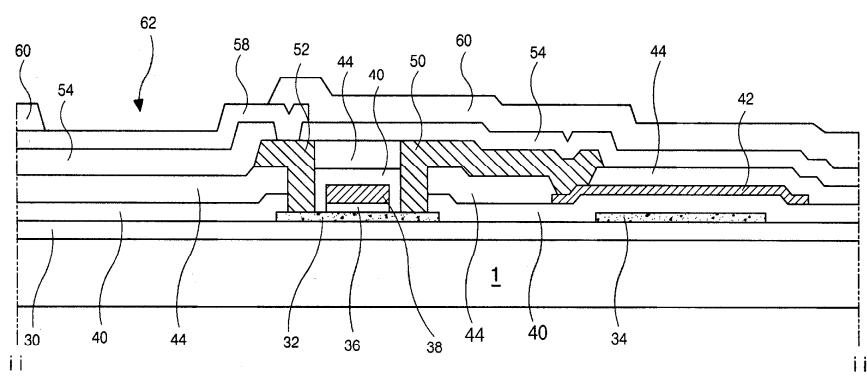
4f



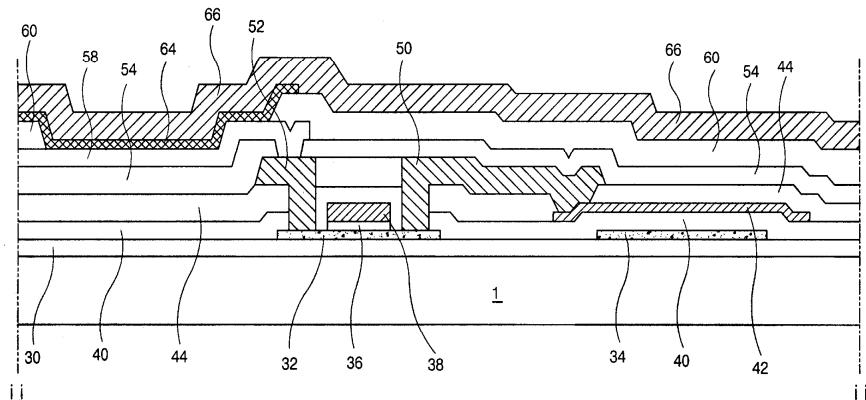
4g



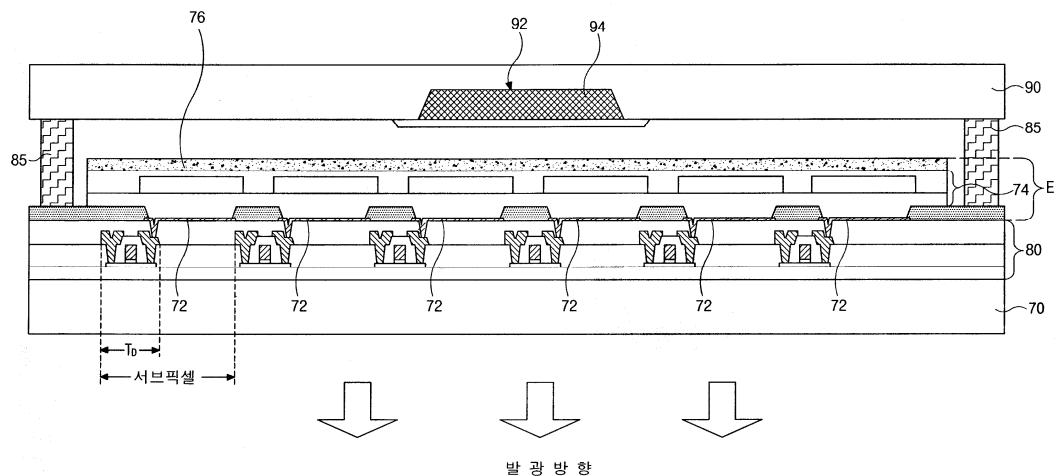
4h



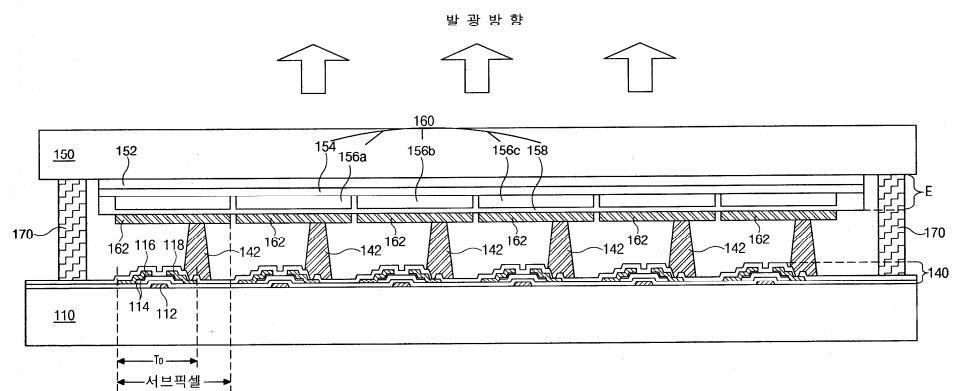
4i



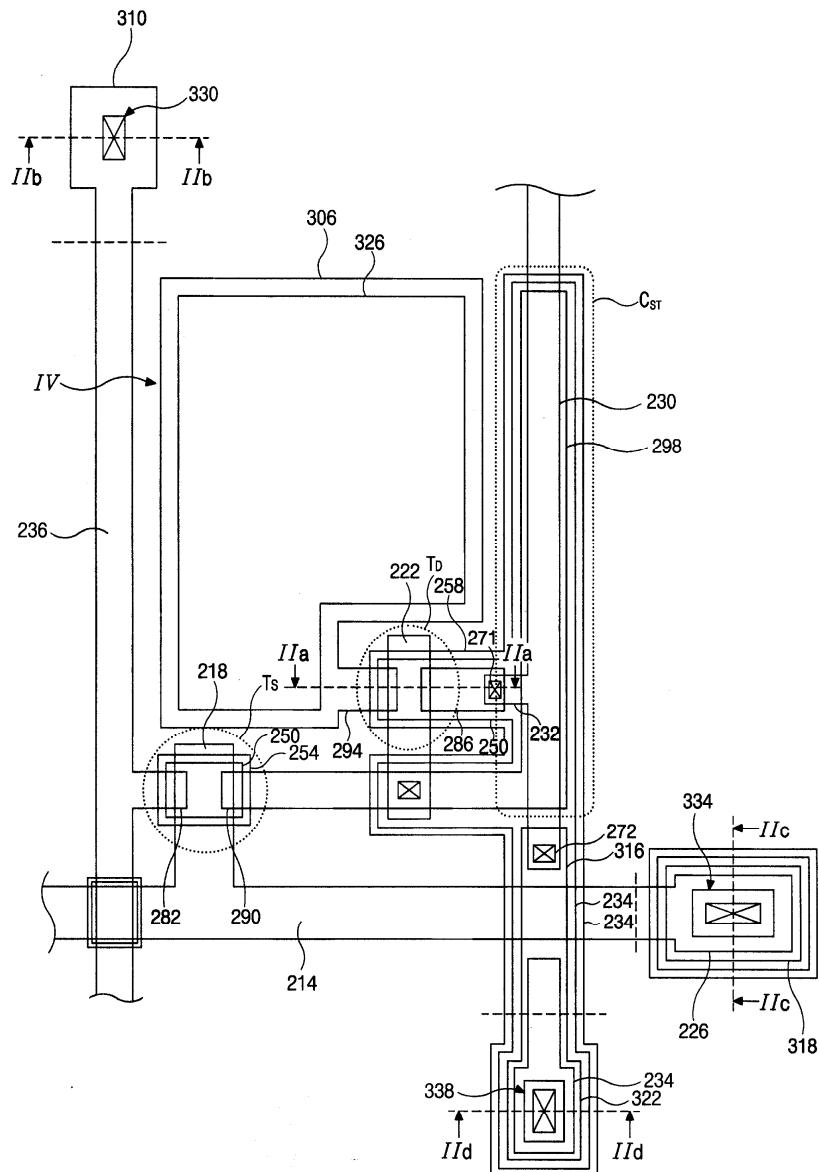
5



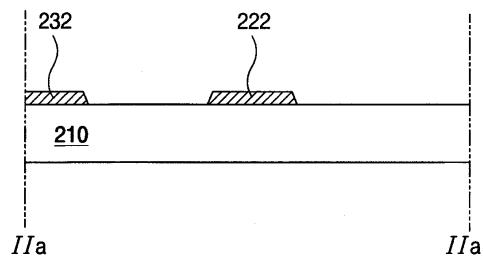
6



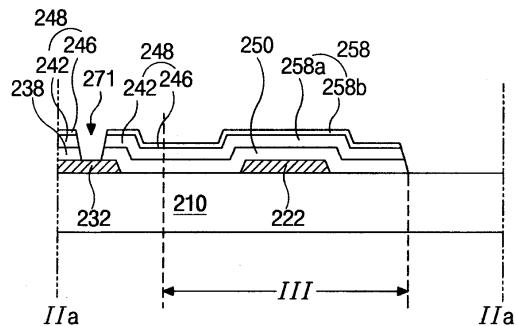
7



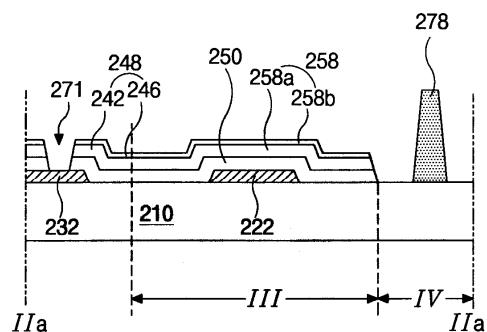
8a



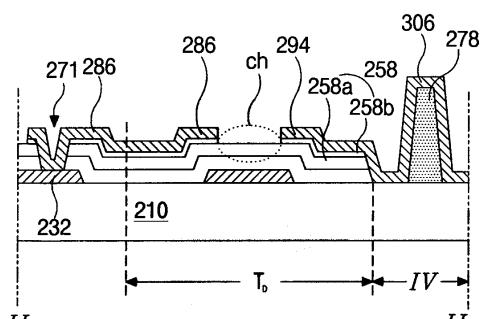
8b



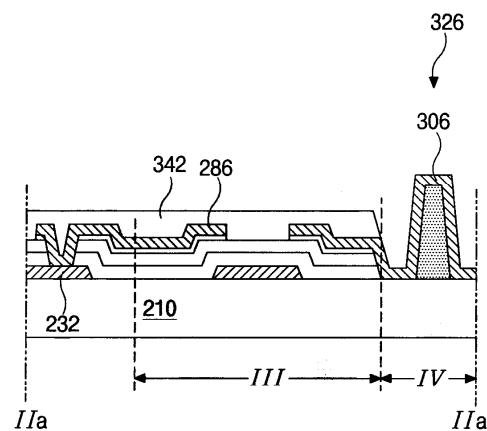
8c



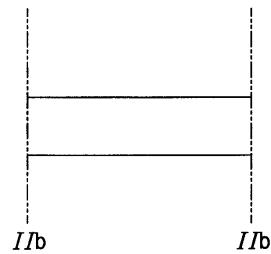
8d



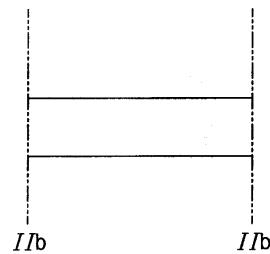
8e



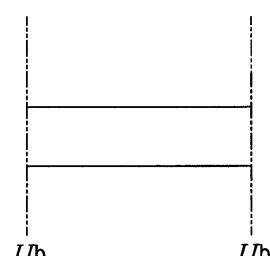
9a



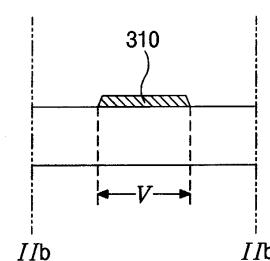
9b



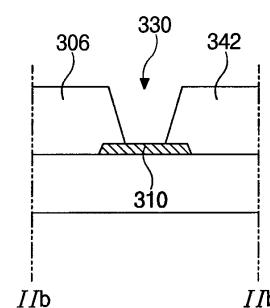
9c



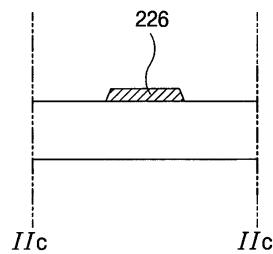
9d



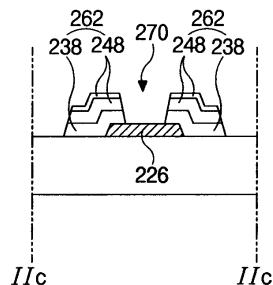
9e



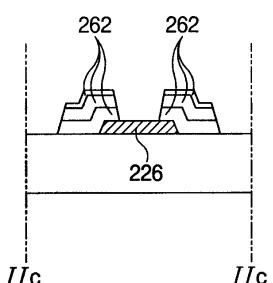
10a



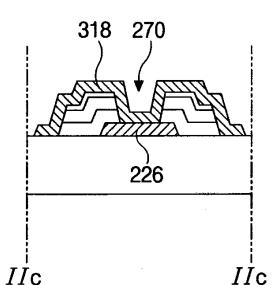
10b



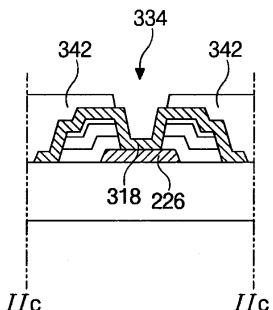
10c



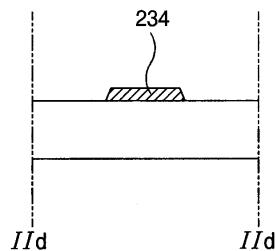
10d



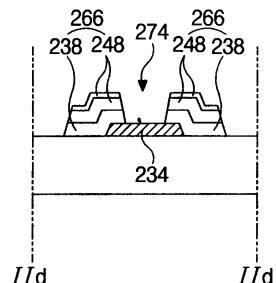
10e



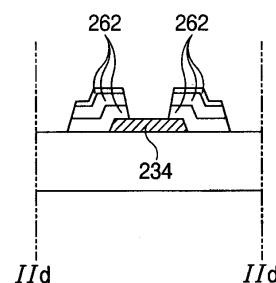
11a



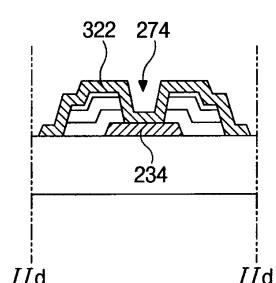
11b



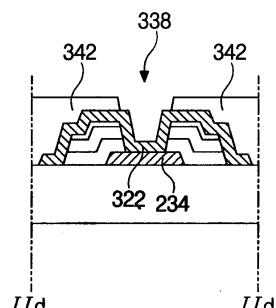
11c



11d



11e



专利名称(译)	双面板型有机电致发光器件及其制造方法		
公开(公告)号	<a href="#">KR1020040058447A</a>	公开(公告)日	2004-07-05
申请号	KR1020020084578	申请日	2002-12-26
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG显示器有限公司		
当前申请(专利权)人(译)	LG显示器有限公司		
[标]发明人	PARK JAEYONG 박재용 HWANG KWANGJO 황광조		
发明人	박재용 황광조		
IPC分类号	H01L27/32 H01L51/50 G09F9/30 H05B33/10 H01L29/786		
CPC分类号	H01L27/3253 H01L27/3262		
其他公开文献	KR100497095B1		
外部链接	<a href="#">Espacenet</a>		

### 摘要(译)

根据本发明的双面板型有机电致发光器件及其制造方法，首先，由于阵列元件和有机电致发光二极管元件形成在不同的基板上，因此可以提高产量和生产管理效率，第二，由于它是顶部发射型，因此可以容易地设计薄膜晶体管并实现高孔径比/高分辨率。第三，使用非晶硅材料的反向交错型薄膜晶体管结构可以用于低温工艺，即使添加单独的电连接图案，与常规的相比，掩模工艺的数量也可以减少，这是有利的，因为通过简化工艺可以有效地提高产量。图8E

